

# Course Syllabus

ภาควิชา : วิศวกรรมไฟฟ้า

ชื่อวิชา : Physical Electronics

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**Corequisite :** 315 112 Fundamentals of Physics II

**Textbooks :** R. T. Howe and C. G. Sodini, "Microelectronic : An Integrated Approach", Prentice-Hall, 1997.

**Recommendation Reading :**

1. C. G. Fonstad "Microelectronic Devices and Circuits", McGraw-Hill, 1994.
2. G. Parker, "Introductory Semiconductor Device Physics", Prentice Hall, 1994.
3. M. S. Tyagi, "Introduction to Semiconductor Materials and Devices", John Wiley & Sons Inc, 1991.
4. J. Singh, "Semiconductor Devices: An Introduction", McGraw-Hill International Editions, 1994.
5. R. M. Warner, Jr. and B. L. Grung, "Semiconductor Devices-Electronics", HRW Saunders International Editions, 1991.
6. B. G. Streetman, "Solid State Electronic Devices", Prentice Hall, 1990.
7. D. A. Neamen, "Semiconductor Physics and Devices : Basic Principles", Irwin Inc, 1992.
8. R. S. Muller and T. I. Kamins, "Device Electronics for Integrated Circuits", 2<sup>nd</sup> Edition, John Wiley & Sons Inc, 1986.
9. R. F. Pierret, "Semiconductor Device Fundamentals", Addison-Wesley Publishing Company, 1996.
10. IEEE Journal on Solid-State Circuits (SC), IEEE Transaction on Electron Devices (ED), and IEEE Electron Devices Letter (EDL).

**Objective :**

1. To give introductory concepts of the underlying physics of semiconductor devices.
2. To provide a basis for understanding the characteristics, operation, and limitations of semiconductor devices.

**Examination :**

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|-----------------------------|------|
| 1. Midterm Test             | 40 % |
| 2. Final Test               | 50 % |
| 3. Attention and Assignment | 10 % |

**Language of Lecture :** Thai

**Language of Examination :** English

**Course Description :**

ทฤษฎีพื้นฐานเกี่ยวกับโซลิดสเตต สารกึ่งตัวนำ เทคโนโลยีในการสร้างสารกึ่งตัวนำ การไดป์สาร รอยต่อ พี-เอ็น รอยต่อสารกึ่งตัวนำกับโลหะ ไบโพลาร์และเฟททรานซิสเตอร์ วงจรรวม อุปกรณ์อิเล็กทรอนิกส์ที่เกี่ยวกับแสง และอุปกรณ์อิเล็กทรอนิกส์ที่ใช้กำลังสูง

Basic theory of solid-state, Semiconductors, Fabrication technologies, Doping, P-N Junction, Semiconductor-Metal junction, Bipolar and FET transistors, Integrated circuits, Optical and power semiconductor devices.

<b>Chapter</b>	<b>Topics</b>	<b>Hours</b>
<b>2</b>	<b>Introduction</b> <ul style="list-style-type: none"> <li>• Introduction to Physical Electronics</li> <li>• Semiconductor Physics</li> </ul>	<b>2</b> 1 1
<b>3</b>	<b>PN Junction and MOS Electrostatics</b> <ul style="list-style-type: none"> <li>• Applied Electrostatics</li> <li>• Carrier Concentration and Potential in Thermal Equilibrium</li> <li>• The PN Junction</li> <li>• Depletion Capacitance</li> <li>• The MOS Capacitor</li> <li>• The Electrostatics of the MOS Capacitor</li> <li>• Capacitance of the MOS Structure</li> </ul>	<b>10</b> 2 1 2 1 2 1 1
<b>4</b>	<b>The MOS Field Effect Transistor</b> <ul style="list-style-type: none"> <li>• Device Physics of the MOSFET</li> <li>• MOSFET Circuit Models</li> </ul>	<b>6</b> 3 3
<b>6</b>	<b>The PN Junction Diode</b> <ul style="list-style-type: none"> <li>• PN Junction Diode Circuit Models</li> <li>• SPICE Model of the PN Junction Diode</li> <li>• Minority Carrier Distributions and Current Components</li> </ul>	<b>6</b> 3 1 2
<b>7</b>	<b>The Bipolar Junction Transistor</b> <ul style="list-style-type: none"> <li>• Physics of Bipolar Junction Transistor</li> <li>• The Ebers-Moll Equations</li> <li>• Small Signal Model of the Bipolar Junction Transistor</li> <li>• Lateral pnp Bipolar Transistor</li> </ul>	<b>6</b> 2 1 2 1
<b>Total</b>		<b>30</b>